

Yoshiaki Daimon Hagiwara BIO

Born on July 4, 1948 in Kyoto Japan and lived in Kyoto Japan till 1965. Moved to live in Riverside California USA in 1965 and graduated from Riverside Polytechnic High School in 1967. Lived in Pasadena California from 1967 till 1975. Studied and graduated with BS71, MS72 and PhD75 from California Institute of Technology. Joined Sony in 1975 and worked for building semiconductor LSI chip sets. After the retirement from Sony in 2008, taught at Sojo University in Kumamoto City in Japan till 2017. Currently, serving as an operational committee member of Society of Semiconductor Industry Specialists (SSIS) in Japan and also serving as the chairman of the SSIS Education Committee.

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